

# **Synthesis, electrochemical and photoluminescence properties of titanium nitride nanoparticles**

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Received: 3 April 2018 / Accepted: 17 April 2018 / Published online: 28 April 2018 © Springer Science+Business Media, LLC, part of Springer Nature 2018

#### **Abstract**

Titanium nitride nanoparticles were efficiently synthesized by molten-salt method in  $MgCl<sub>2</sub>–NaCl$  media at a low temperature of 700 °C for 1 h, using titanium dioxide and Mg as raw materials in a  $N_2$  atmosphere. The investigations of nanostructure analysis indicate that the as-prepared titanium nitride is a pure phase, and has excellent crystallinity and high Brunauer– Emmett–Teller surface area. Electrochemical tests show that the titanium nitride nanoparticles exhibit a specific capacitance of 26.4 F/g at 0.25 A/g discharge current density and a low internal resistance (Rs) of 2.0 Ω. The photoluminescence spectrum shows four prominent and high intense peaks centered at 279, 420, 561 and 838 nm, suggesting the good optical property of the titanium nitride nanoparticles.

# **1 Introduction**

Titanium nitride (TiN) has attracted considerable attention from researchers due to its excellent properties such as high melting point, extreme hardness, good adhesion to the substrate, excellent corrosion resistance, good electrical conductivity and favorable optical properties [\[1](#page-5-0)[–6\]](#page-5-1). In recent years, TiN materials have been exploited systematically in applications for catalyst supports [[7](#page-5-2)], additive [[8\]](#page-5-3), energysaving coatings [[9\]](#page-5-4), photocatalytic applications [[10\]](#page-5-5), supercapacitors [[11\]](#page-5-6), electrode materials [[12\]](#page-5-7) and so on.

There are several methods employed for the synthesis of TiN nanoparticles, including carbothermal reduction nitridation [[13](#page-5-8)], self-propagating high-temperature synthesis [\[14\]](#page-5-9), a sol–gel method  $[15]$  $[15]$  $[15]$ , low-temperature and solventfree synthesis [[16](#page-5-11)], and chemical vapor deposition [[17](#page-5-12)]. However, some of these methods have a complex reaction process that is expensive and somewhat unfriendly to the environment. In addition to the above techniques, molten salt synthesis (MSS) has been reported to be one of the most low-temperature and cost-effective means to prepare nitride powders and ceramic materials [[18](#page-5-13)[–29](#page-5-14)].

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In this study, the TiN nanoparticles were synthesized by MSS at 700 °C for 1 h, using titanium dioxide (TiO<sub>2</sub>) and Mg as raw materials in MgCl<sub>2</sub>–NaCl media in a N<sub>2</sub> atmosphere. In addition, the electrochemical and photoluminescence properties of the TiN nanoparticles were revealed.

## **2 Experimental procedure**

TiN nanoparticles were obtained by using powders of  $TiO<sub>2</sub>$ (99.0% in purity) and Mg (99.5% in purity) at a 1:2.5 mol ratio as the raw materials. MgCl<sub>2</sub>·6H<sub>2</sub>O (99.0% in purity) and NaCl (99.5% in purity) at a 1:4 mol ratio were used as the reaction medium. The raw materials and two kinds of salts were mechanically mixed at a weight ratio of 1:1.2 in an alumina crucible and then heated at the temperature of 700 °C for 1 h in a  $N_2$  atmosphere. After cooling down to room temperature, the reacted mass was wash by hydrochloric acid solution (0.5 mol/L) and distilled water to remove the by-products and the residual salt. The final samples were then oven-dried at 110 °C for 12 h prior to further characterizations.

Phase analysis about the product was made by powder X-ray diffraction (XRD, Philips, X'Pert Pro) using Cu Kα radiation. The morphology of the nanostructure was determined by high-resolution transmission electron microscopy (HRTEM, JEOL, JEM2000F) equipped with an energy dispersive X-ray spectroscope (EDS). The X-ray photoelectron spectra (XPS) were conducted on a VG Multi lab 2000 spectrometer (Thermo

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Electron Corporation) with Al Kα radiation (hv= $1486.6$  eV) as the incident X-ray. A Brunauer–Emmett–Teller (BET) specific-surface-area analysis was conducted to characterize the powders using a fully automatic surface area and porosity analyzer (Quantachrome, Autosorb-1-MP). The electrochemical performance of the material was analyzed on an electrochemical workstation (CHI 760E, Shanghai, China). Photoluminescence (PL) spectra were detected by a fluorescence spectrophotometer (Jobin Yvon, FL3-32, French) at room temperature.

## **3 Results and discussion**

#### **3.1 Crystal structure**

Figure [1](#page-1-0) shows the XRD pattern of the as-obtained sample. The five intense diffraction peaks at a 2θ of 36.850°, 42.822°, 62.173°, 74.365°, and 78.265° can be readily indexed as the cubic cell of TiN [(111), (200), (220), (311), and (222)], which indicate the high crystallinity and purity of TiN. The reference interplanar distances of the TiN phase (JCPDS file no. 38-1420) in comparison with XRD result are shown in Table [1](#page-1-1). The values of interplanar distances for the as-prepared TiN differ from the JCPDS file no. 38-1420 data no more than 0.02 Å. The lattice constant for TiN nanoparticles has been determined to be  $a = 4.22$  Å, which is consistent with the literature value (JCPDS file no. 38-1420). The crystallite size of the TiN nanoparticle is calculated to be 27 nm using the Debye–Scherrer relationship [\[30](#page-5-15)].

#### $D = 0.9\lambda/(\beta \cos \theta)$

where D denotes the crystallite size (nm);  $β$  denotes the full width at half-maximum;  $\lambda$  denotes the incident X-ray wavelength and θ denotes the diffraction angle.



<span id="page-1-0"></span>**Fig. 1** XRD pattern of the TiN sample synthesized at 700 °C for 1 h

<span id="page-1-1"></span>**Table 1** Reference interplanar distences of the TiN phase in comparison with XRD result

Crystal plane	Interplanar distances d (A)		
	JCPDS file no. 38-1420	XRD result	
111	2.4492	2.4372	
200	2.1207	2.1101	
220	1.4997	1.4919	
311	1.2789	1.2746	
222	1.2245	1.2205	

#### **3.2 Morphologies**

The morphology and crystal structure of the final TiN nanoparticles can be observed in Fig. [2.](#page-2-0) The HR-TEM image clearly shows the structural feature of the nanoparticles, as shown in Fig. [2a](#page-2-0). It also can be observed that the TiN particles exist obvious aggregation with smaller grown nanoparticles, exhibiting a large surface area (will be discussed later). The spacing between adjacent lattice planes is measured to be 0.25 nm, corresponding to the (111) plane of TiN. However, these lattice frings are in different orientations (Fig. [2](#page-2-0)b), indicating the polycrystalline nature of the TiN nanomaterial, which is consistent with the result of the selected area electron diffraction (SAED) pattern (inset in Fig. [2d](#page-2-0)) of the sample. The d-spacings from inside to outside sequentially at 2.37, 2.04, 1.49 and 1.21 Å can be indexed to the (111), (200), (220) and (311) planes of the cubic phase, corresponding to the XRD result.

#### **3.3 XPS investigations**

The XPS spectra of the final TiN sample are shown in Fig. [3.](#page-3-0) The full range XPS spectrum in Fig. [3a](#page-3-0) clearly shows that the TiN sample surface mainly consists of titanium, nitrogen, carbon and oxygen. In addition to the reference carbon, the oxygen peaks observed may be due to the incomplete oxide reaction. The Ti2p spectrum of TiN nanoparticles is also given in Fig. [3](#page-3-0)b, in which the deconvolution of the Ti2p peak shows two components: TiN (Ti2p3/2: 454.9 eV, Ti2p1/2: 460.5 eV) and TiO<sub>2</sub> (Ti2p3/2: 458.5 eV, Ti2p1/2: 464.1 eV) [[31,](#page-5-16) [32](#page-5-17)]. Figure [3c](#page-3-0) shows the N1s bands of the TiN nanoparticles. The major N1s peak at 396.1 eV can be indexed to the typical nitrogen shifts of TiN component, while the other two peaks at 397.1 and 398.7 eV are attributed to N–Ti on the TiN surface or impurities  $[31]$  $[31]$ . The quantitative analysis of the elements at the sample surfaces is given in Table [2,](#page-3-1) using the elemental sensitivity factor method.



<span id="page-2-0"></span>**Fig. 2** TEM images of the TiN sample synthesized at 700 °C for 1 h: **a** and **b** HR-TEM image of the as-prepared TiN; **c** low-magnification TEM image of the as-prepared TiN; **d** SAED pattern obtained from (**c**)

## **3.4 BET surface area and pore size distribution**

Figure [4](#page-3-2) shows the  $N_2$  adsorption–desorption isotherm and the corresponding pore size distribution curve of the TiN sample. The specimen is classified type-IV, which indicates the presence of mesopores [[33](#page-5-18)]. The high  $N_2$  adsorption values at the  $P/P_0$  between 0.6 and 1.0, indicative of the existence of large mesopores, corresponging to the pore size distribution curve (inset of Fig. [4](#page-3-2)), showing a wide range of 1–30 nm with a peak pore diameter of  $\sim$  3 nm. The BET surface area of the TiN nanoparticles is calculated to be  $107.748 \text{ m}^2/\text{g}$ .

## **3.5 Electrochemical performance**

TiN served as working electrode directly, carbon rods as the counter electrode, a saturated calomel electrode (SCE) as reference electrode and tested in three-electrode system with 1 M  $Na<sub>2</sub>SO<sub>4</sub>$  solution. The capacitance of TiN was studied by cyclic voltammetry (CV) method at different scan rates of 10, 20, 50, 100 and 200 mV/s. The CV curves have a similar rectangular shape indicating the excellent conductivity of TiN (Fig. [5](#page-4-0)a). At the same time, the galvanostatic charge–discharge (GCD) curves are also showing the highly symmetry and exhibiting short voltage drop at current densities from 0.25 to 4 A/g (Fig. [5](#page-4-0)b). Therefore, we calculate the capacity of TiN used the following equation: [\[34\]](#page-5-19)

#### $C = I\Delta t/\Delta V$

where C denotes the mass specific capacitance (F/g);  $\Delta t$ denotes the discharge time; I denotes the current density and  $\Delta V$  denotes the potential window. The capacitance of TiN is 26.4 F/g at 0.25 A/g and 9.9 F/g at 4 A/g, respectively. Because of the excellent conductivity of TiN, the capacitance of TiN is remain 50% when the current density is aggrandize 16 times from 0.25 to 4 A/g. Figure [5](#page-4-0)d shows the Nyquist plots of the electrochemical impedance spectroscopy (EIS) for the TiN nanoparticles. The magnified spectrum in high frequency regions shows a low internal resistance (Rs) of 2.0  $\Omega$  for TiN nanoparticles (inset in Fig. [5](#page-4-0)d), implying the good conductivity of the sample.



<span id="page-3-0"></span>**Fig. 3** XPS spectra of the TiN sample synthesized at 700 °C for 1 h: **a** Full XPS spectrum; **b** Ti2p spectrum; **c** N1s spectrum

<span id="page-3-1"></span>**Table 2** Elemental quantitative analysis using XPS for the TiN sample synthesized at 700 °C for 1 h

	FWHM (eV)	Raw area	RSF	Atomic conc. $(\%)$
Ti <sub>2</sub> p	1.390	101233.5	2.001	20.16
N <sub>1s</sub>	1.999	14516.4	0.477	12.27
O <sub>1s</sub>	1.444	87226.3	0.780	44.12

The RSF is the relative sensitivity factor

### **3.6 Photoluminescence (PL) property**

The PL technique has been widely used to study the optical and photochemical properties of semiconductor materials [[35–](#page-6-0)[37](#page-6-1)]. The PL spectrum of the TiN sample recorded at room temperature is shown in Fig. [6](#page-4-1). The PL emission of the TiN nanoparticles, which was measured at 845 nm excitation wavelength, is composed of four prominent and high intense peaks centered at 279 (4.44), 420 (2.95), 561 (2.21) and 838 (1.48 eV) nm. The peaks centered at 420



<span id="page-3-2"></span>**Fig. 4** Nitrogen adsorption–desorption isotherm and the corresponding pore-size distribution curve (inset) of the TiN sample synthesized at 700 °C for 1 h



<span id="page-4-0"></span>**Fig. 5** Electrochemical performance of the TiN sample synthesized at 700 °C for 1 h: **a** CV curves at different scan rates; **b** GCD curves; **c** Specific capacitance at different current densities; **d** Nyquist plots



<span id="page-4-1"></span>**Fig. 6** Emission photoluminescence spectrum of the TiN sample synthesized at 700 °C for 1 h

and 561 nm are good evidences that the TiN nanoparticles could be applied as photoluminescence material.

## **4 Conclusions**

In this work, TiN nanoparticles have been efficiently synthesized by molten-salt method in  $MgCl<sub>2</sub>–NaCl$  media at a low temperature of 700 °C for 1 h, using TiO<sub>2</sub> and Mg as raw materials in a  $N_2$  atmosphere. It is found that the final TiN is a pure phase and highly crystalline, and has a high BET surface area  $(107.748 \text{ m}^2/\text{g})$ . The specific capacitance of the TiN nanoparticles is 26.4 F/g at 0.25 A/g discharge current density and the internal resistance (Rs) is as low as  $2.0 \Omega$ . The photoluminescence emission spectrum is measured at an excitation wavelength of 854 nm and four prominent and high intense peaks centered at 279, 420, 561 and 838 nm are observed.

**Acknowledgements** The authors acknowledge financial support from the National Natural Science Foundation of China (Grant Nos. 51502215, 51574187 and 51602232).

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